www.hidenanalytical.com info@hiden.co.uk



Hiden SIMS

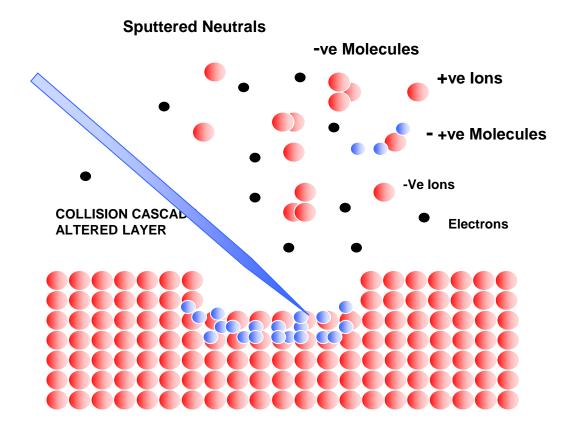
Analytical Secondary Ion Mass Spectrometry Products







Sputter Erosion of the Specimen





Sputter Erosion of the Specimen

Static SIMS

- •Very low ion dose (~1E12 ions cm⁻²) gives surface specific measurement.
- Ideal for investigation of contamination, oxidation and monolayer coatings.

Dynamic SIMS

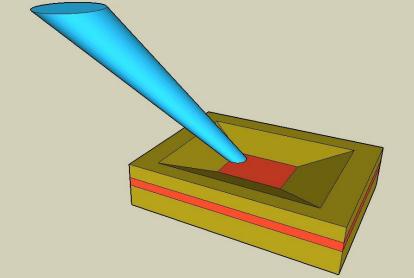
- Higher ion dose erodes surface exposing deeper material.
- Monitoring mass resolved ion signals results in depth profile.
- Ideal for investigation of impurities (dopants) and layer structures



Introduction to SIMS – sputter erosion of the specimen

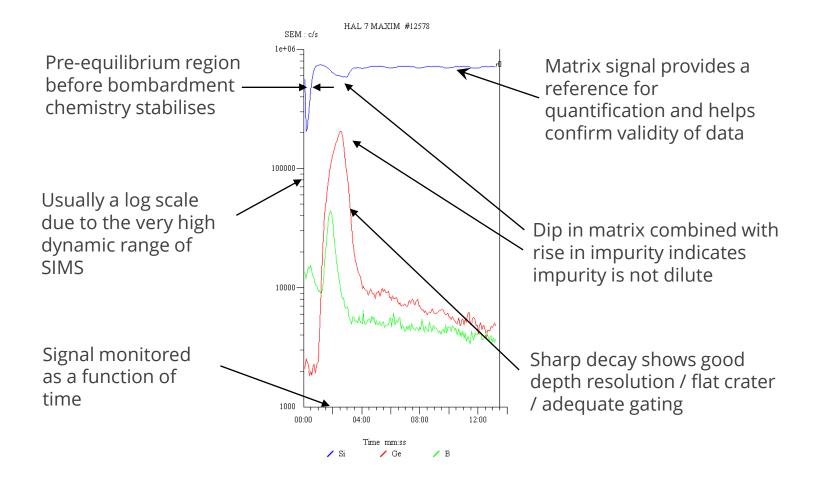
Scanning the beam across the sample

- Flat bottom crater
- Imaging collect data as a function of position
- Gating, only collect data when the beam is in the central flat part of the crater for high dynamic range depth profiles.





Anatomy of a Depth Profile





Primary ion beams

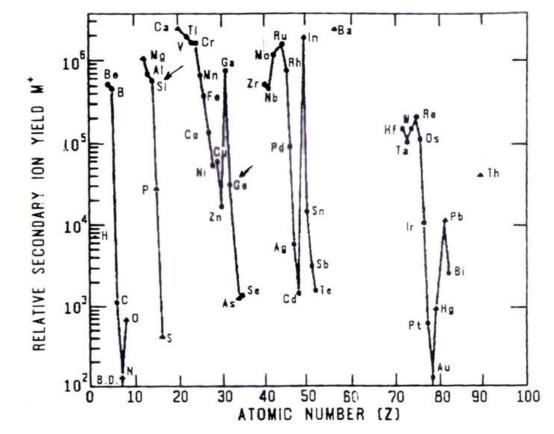
The probability of ion emission is affected greatly by the sample chemistry.

As the ion beam species becomes incorporated into the specimen it can be used to modify the surface chemistry and enhance probability of ionised emission.

- Oxygen enhances ionisation of electropositive elements
 - many metals and semiconductor matrix species
- Caesium enhances ionisation of electronegative elements
 - halogens, many contamination species, some metals
- Caesium can also be used to collect secondary ion cluster
 - (MCs⁺) of most species (M) at lower sensitivity but better linearity at high concentration.



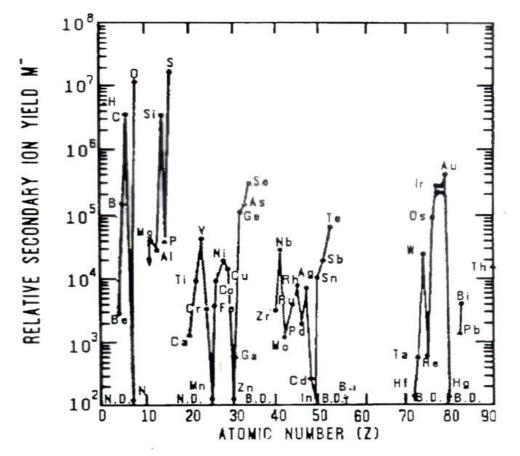
Relative Ion Yields - Positive SIMS Oxygen Primary Ions



SIMS Handbook ed : Wilson R.G.; Stevie, F.A.; Magee, C.W.; John Wiley & Sons Inc. NY 1989



Relative Ion Yields - Negative SIMS Caesium Primary Ions



SIMS Handbook ed : Wilson R.G.; Stevie, F.A.; Magee, C.W.; John Wiley & Sons Inc. NY 1989



Recommended Primary Ions

Element	lp	lon	Notes	Element	lp	lon	Notes
н	Cs	H-	2H if implant	Kr	O2	Kr+	or KrCs+ with Cs
He	02	He+	No for HeCs+	Rb	O2	Rb+	
Li	O2	Li+		Sr	O2	Sr+	
Be	O2	Be+	HMR in AlGaAs (Al3+)	Y	O2	Y+	
В	O2	B+	BSi- also works	Zr	O2	Zr+	
С	Cs	C-	CM- can give better DL	Nb	O2	Nb+	
N	Cs	NM-	use N-15 if implanting	Mo	O2	Mo+	
0	Cs	0-	use O-18 if implanting	Ru	O2	Ru+	or Ru- with Cs
F	Cs	F-		Rh	O2	Rh+	or Rh- with Cs
Ne	02	Ne+	or NeCs+	Pd	O2	Pd+	or Pd- with Cs
Na		Na+		Ag	O2	Ag+	or Ag- with Cs
Mg		Mg+		Cd	O2	Cd+	or CdCs+. No Cd- ion
Al	02	Al+		In	O2	In+	
Si	Cs	Si-		Sn	O2	Sn+	or Sn- with Cs
Р	Cs		or P+ with O2 (HMR in Si)	Sb	Cs	Sb-	or SbM- or Sb+ with O2.
S	Cs		orS+ with O2 (HMR in Si)	Те	Cs	Te-	
CI	Cs	CI-		l I	Cs	l-	
Ar	02	Ar+	or ArCs-	Xe	O2	Xe+	no XeCs+
К	02			Cs	O2	Cs+	
Ca		Ca+		Ва	O2	Ba+	HMR in GaAs
Sc		Sc+		La	O2	La+	all La rare earths as La
Ti	02		or Ti- with Cs	Hf	02	Hf+	no Hf- ion
V	02		or V- with Cs	Та	O2	Ta+	
Cr		Cr+		W	02	W+	
Mn		Mn+	no Mn- ion	Re	02	Re+	
Fe		Fe+	HMR in Si. Fe54 for implant	Os	Cs	Os-	or Os+ with O2
Co		Co+	HMR in Si	Ir	Cs	lr-	
Ni		Ni+	or Ni- with Cs. HMR in Si	Pt	Cs	Pt-	
Cu		Cu+	or Cu- with Cs.	Au	Cs	Au-	
Zn		Zn+	or ZnCs+	Hg	02	Hg+	or HgCs+. no Hg- ion
Ga		Ga+		TI	02	Tl+	
Ge		Ge-	or 70Ge+ with O2	Pb	02	Pb+	HMR in GaAs
As			or 75As- HMR in Si	Bi	Cs	Bi-	or BiM- or Bi+ with O2
Se		Se-		Th	02	Th+	
Br	Cs	Br-		U	02	U+	

www.HidenAnalytical.com

info@hiden.co.uk



Hiden SIMS Products

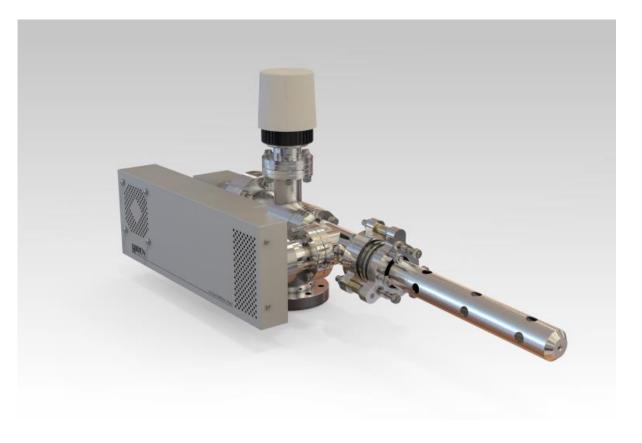
- Ion Guns
 - Inert gas
 - Reactive gas
 - Caesium
- Spectrometers
 - Basic
 - Energy analysing (surface science)
 - High transmission (surface analysis)
- Complete systems
 - SIMS Workstation family
 - SIMS on a flange
 - Compact SIMS
- Customisation
 - Addition of other techniques and special configurations



Hiden SIMS Products – Ion Guns

IG20 Gas Ion Gun

- •1-5 keV, 0.5 μA, 100μm (50μm imaging)
- •Reliable, long life, electron impact ion source
- •Integral bend to remove neutral particles
- •May be used with reactive and inert gases (e.g. H, He, O, N, Ar, Xe, air)
- •Differential pumping to preserve chamber UHV
- •Bakeable to 250°C
- •Mounts on CF35





Hiden SIMS Products – Ion Guns



IG5C Caesium Ion Gun

- •1-5 keV, 150nA, 80µm (20µm imaging)
- •Miniature low power Cs Ion source (~8W), long life, easy replacement.
- •Air stable
- •Double bend to remove neutral particles
- •Differential pumping to preserve chamber UHV
- •Bakeable to 250°C
- •Mounts on CF35



Hiden SIMS Products – Ion Guns

Ion Gun Control

PC controlled

Settings can be saved and recalled

Automatic ion source warm up / cool down

EHT ramp rate control

Gun diagnostics

Connect via TCP/IP, USB or serial

Upgradeable software and firmware





Hiden SIMS Products – Spectrometers

Secondary Ion Mass Spectrometers

- SIM Basic on-axis probe, positive ion only
- EQS 45° electrostatic sector for mass and energy measurement, excellent energy filtering, on-axis collection
- MAXIM 30° off axis collection, maximum sensitivity, integrated SNMS

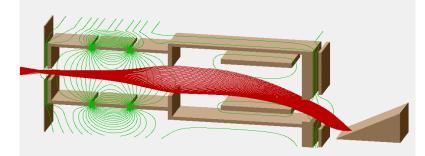


Hiden SIMS Products – Spectrometers

MAXIM – High Performance SIMS and SNMS



Easy to change filament for SNMS





Off-axis collection



Hiden SIMS Products – Spectrometers

EQS – On-axis sampling, energy resolving mass spectrometer

Easily fits to other surface analysis and FIB tools







Zeiss Nvision X-beam FIB with EQS





Modular SIMS

Complete SIMS on a single flange (IG20 + EQS + spare ports)

- Positive and negative ions
- Oxygen and Inert gas ion gun (Cs option)
- Sample viewing
- Aligned port for charge compensation electron gun
- Large range of working distance and off axis analysis position can be specified



Mounted on a surface analysis chamber



Mounted on an MBE system preparation chamber



Hiden SIMS Workstation



- 3D imaging
- Depth profiling
- Static SIMS
- SNMS
- MAXIM SIMS/SNMS
- Oxygen Ion Gun
- Cs lon Gun
- Electron charge compensation gun
- O₂ gas jet
- Loadlock degas heater
- Large area near sample cryotrap
- UHV bakeable
- Large sample holder
- Normal incidence camera
- Single phase 2500 W
- No compressed air
- Air cooled
- Remote backing pump option
- All dry pumps



Hiden SIMS Workstation – sample mounting



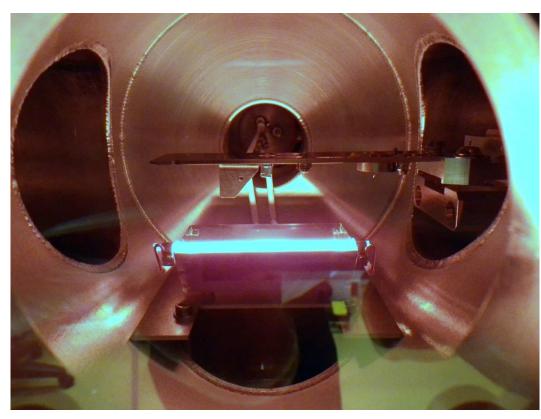




- Samples mount from the underside .
- The upper surface is always in the correct plane for analysis.
- Maximum sample thickness 10mm
- Maximum size to load 40 x 40mm
- Easily customisable sample bar
- Spring clip and screws no adhesive
- Sample bar carries Faraday cup for beam set-up
- Positive bayonet connection and guidance forks make transfer robust and reliable.



Hiden SIMS Workstation – loadlock sample heater



Infra-red sample heating in loadlock

- High purity heater
- Heating sfrom underside (clean top surface)
- Non-contact infra-red
- Uniform heating
- Degas of adsorbed water vapour and volatile compounds.
- Reduced background of hydrogen, oxygen and carbon.
- Preserves UHV environment.



SIMS Workstation with XPS

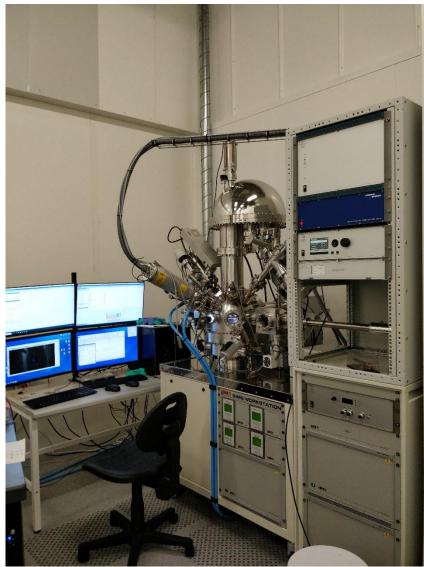
The SIMS workstation is designed to be customisable and has spare ports for the fitting of other techniques or devices.

Here the instrument is configured for SIMS, SNMS and XPS with the addition of the SPECS PHOIBOS 150 analyser and dual anode x-ray source.

A rotation drive allows the sample to be positioned at the optimum angle for XPS or to make angularly resolved measurements.

SIMS Workstation family

The Hiden SIMS Workstation is a modular instrument. All members of the family are based around the same components so it is easily upgradeable from the basic *Foundation* to the fully configured *Plus* version.





Compact SIMS - Overview

The Hiden Compact SIMS tool is designed for fast and easy characterisation of layer structures, surface contamination and impurities with sensitive detection of positive ions being assisted by the oxygen primary ion beam and provides isotopic sensitivity across the entire periodic table.

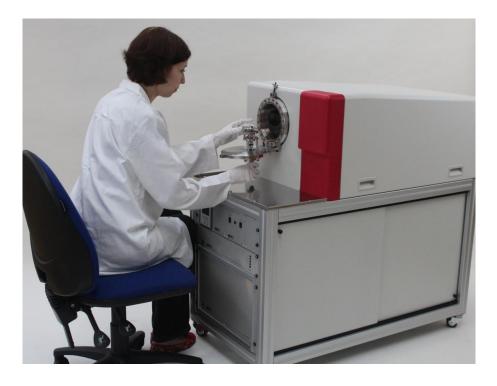
The ion gun geometry is set to provide for ideal nanometre depth resolution and near surface analysis.

Features

- Small footprint
- Easy "user friendly" layout
- Requires only single phase electrical power (under 10A 220Vac)
- Wheeled trolley design
- Positive SIMS and SNMS
- Depth Profiling
- 3D characterisation and imaging
- Mass spectra
- Isotopic analysis

Applications

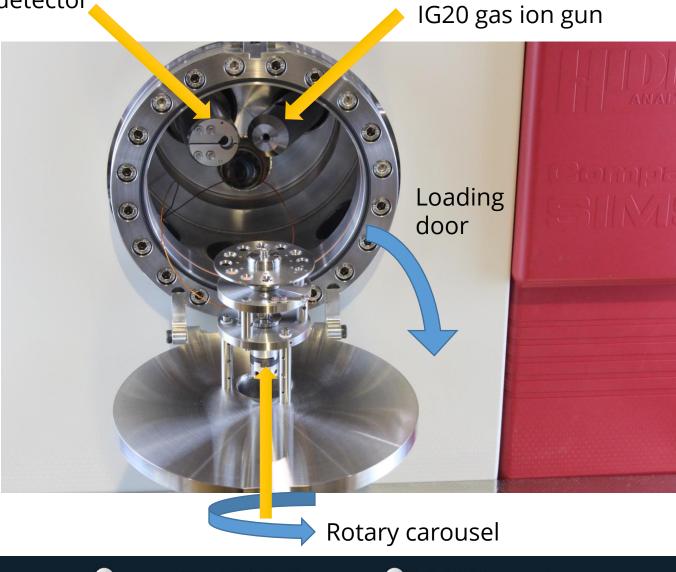
- Thin films
- Surface coatings
- Semiconductors
- Catalysis
- Magnetic media
- Pharmaceuticals
- Corrosion studies
- Nanotechnology





Sample loading

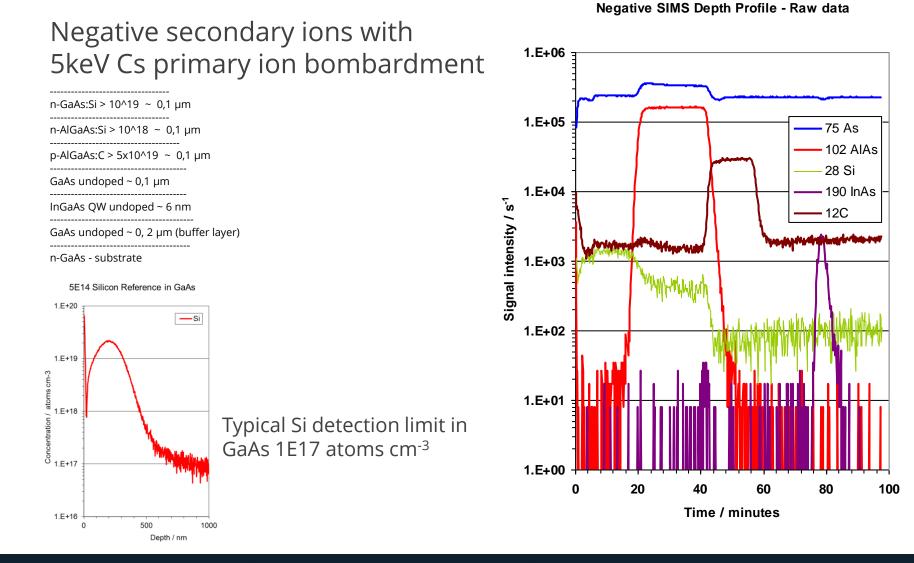
MAXIM-600P SIMS detector



www.HidenAnalytical.com



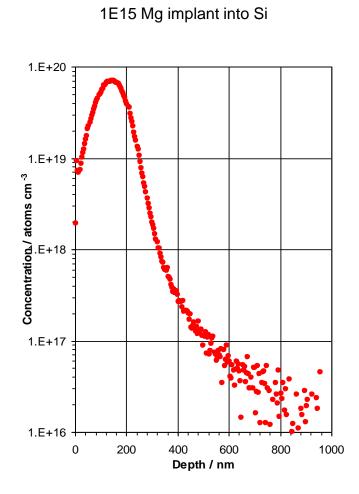
Applications – depth profiling GaAs quantum well structure



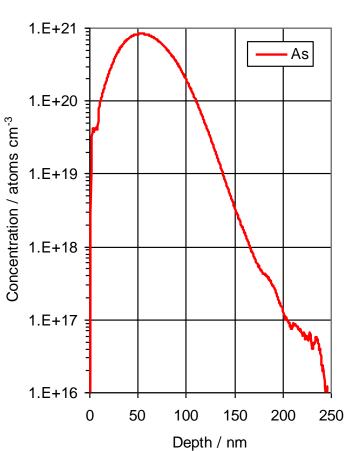
www.HidenAnalytical.com



Applications – depth profiling – Ion Implanted reference materials



²⁴Mg implant in Si, 10¹⁵ atoms cm⁻² analysed using oxygen primary ions from IG20 ion gun on SIMS Workstation with MAXIM spectrometer.



5E15 As implant into Si

As implant in Si, 5x10¹⁵ atoms cm⁻² analysed using 5keV **Cs⁺ primary ions** from IG5C ion gun on SIMS Workstation with MAXIM spectrometer.

info@hiden.co.uk



Depth Profiling – detection limits

Detection limit depends on:

- Ion yield
- Volume of analyte; large volume = better statistics, lower DL, but bigger crater or depth increment
- Background or interfering signals use energy offset to reduce molecular interference, ensure clean surfaces and good ion beam shape, UHV and cold trap to reduce effect of residual gas species (H, O).
- Use 3D data collection to optimise gating

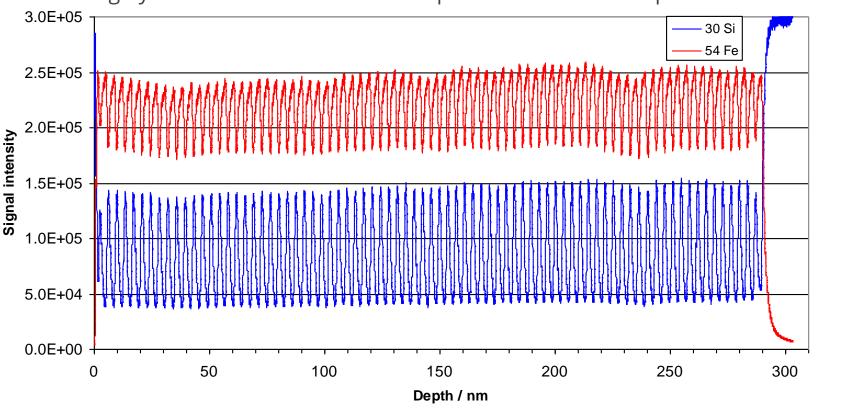
Element	Matrix	Detection limit	Comment
		At/cc	
28 Si	GaAs	8E16	Interference signals from AlH in GaAlAs – 5E17 with background subtraction when possible
11 B	Si	2E16	Surface boron contamination gives rise to background, ultimate shown in clean silicon sample.
31 P	Si	7E17	Interference from SiH at mass 31- energy offset and loadlock degas for best result
2 D	Si	1E18	Subtract contribution from natural H for ultimate DL – use cold trap
2 D	W	2E18	Subtract contribution from natural H for ultimate DL – use cold trap
24 Mg	Si	5E16	
75 As	Si	8E16	
9 Be	Si	2E17	

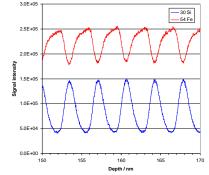


Applications – depth profiling

Depth Profiling Neutron Mirror - 80x 3.6nm Period

A Si/Fe, 80-period, neutron mirror was analysed using normally incident 1.5keV O_2^+ primary ions (100nA) from the IG20 gas gun and detecting secondary ions with the MAXIM SIMS analyser. Although the layers are not fully resolved, the profile shows the thickness to be highly consistent with no loss of depth resolution with depth.





www.HidenAnalytical.com



SNMS (sputtered neutral Mass Spectrometry) – Post Ionisation

The generation of ions during sputtering depends very strongly on the chemistry of the sample and primary ion beam and the ion yield can vary non-linearly over orders of magnitude. This 'matrix effect' makes quantification of SIMS data difficult when impurities reach high concentration (> 2%) or when the matrix varies. Sputtered Neutral Mass Spectrometry overcomes this problem and permits quantification in this extremely useful range by separating the ionisation from the sputtering.

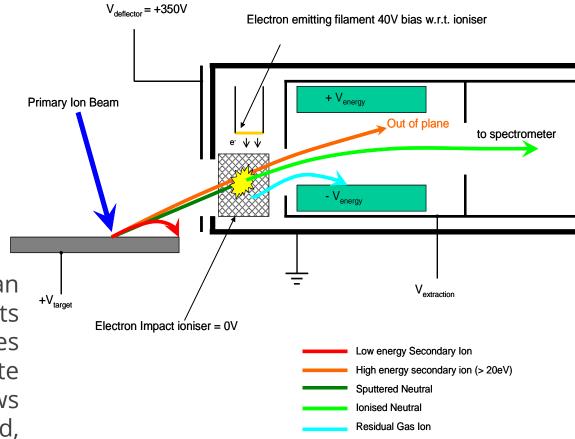
- •Electron impact cell ionises the sputtered neutral material
- •Secondary ions deflected from analyser
- •Separating the sputter and ionisation events removes most of the SIMS matrix effect
- •Easily quantifies large changes in matrix material
- •Detection limit typically <0.1 atomic%
- •Excellent for alloy multilayers
- •No requirement for matrix matched reference materials
- •Neutral species are unaffected by surface charging



SNMS on the MAXIM

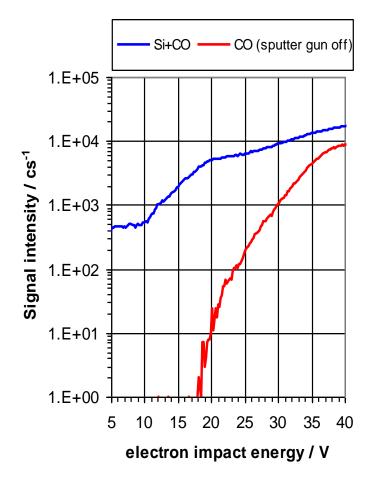


The MAXIM SIMS/SNMS spectrometer has an electron impact ion source fitted close to its entrance. An external deflector plate removes the secondary ions (which generally constitute less than 1% of the sputtered flux) and allows the neutrals to enter the ioniser. Once ionised, the neutrals follow the same path that SIMS ions would have taken.





SNMS with appearance energy discrimination



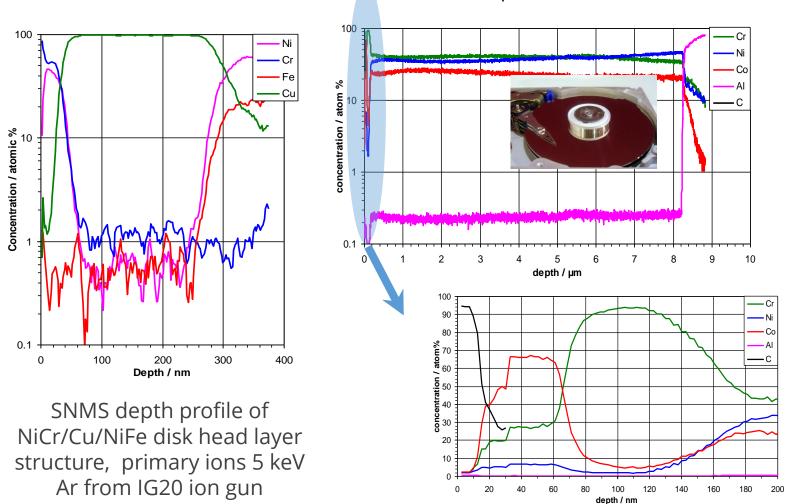
The ability to control the electron impact energy enables some mass interferences to be easily overcome using the ion appearance energy.

For example, CO (mass 28) is a common residual gas constituent and could interfere with the detection of the major isotope of silicon. However, careful choice of the electron energy resolves this problem.

Reducing the electron energy to below 19V prevents ionisation of residual CO, confirmed here by noting the lack of signal with the sputter gun off (red) so with the gun on (blue) the detected signal is from silicon only.



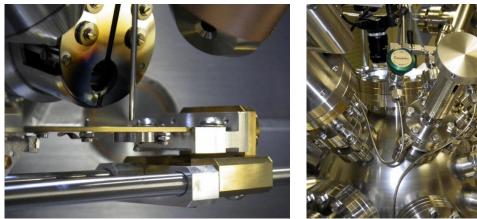
SNMS – Magnetic Storage Materials



SNMS Depth Profile of Hard Disk Platter



Control of surface topography during sputtering – Oxygen jet



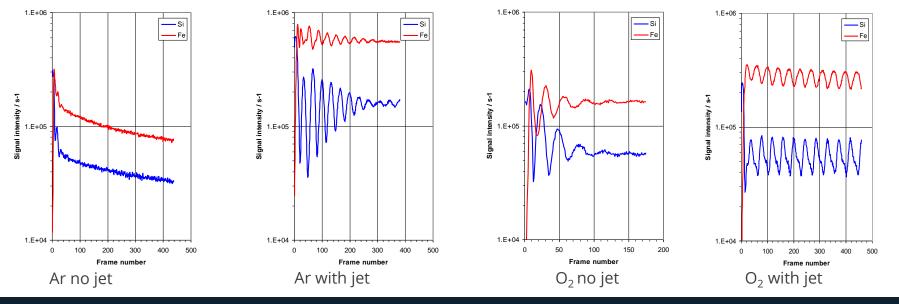


Low energy beams give improved depth resolution but can also induce surface topography.

Fully oxidising the surface using the jet maintains a planar surface and preserves depth resolution.

The jet provides a locally high pressure of pure oxygen over the sample.

2keV 100nA ion beams at 45°. Target 3.6nm Si/Fe multilayer

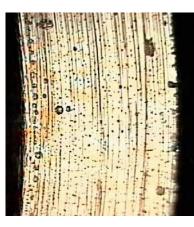


www.HidenAnalytical.com

info@hiden.co.uk



Static SIMS – Contamination on Diesel Injector



After a period of intense engine running, a hard, stain like, deposit was observed on a fuel injector component.

EDX (energy dispersive X-ray) analysis in the SEM was inconclusive as the thin nature of the deposit meant that most of the excited volume was in the underlying metal.

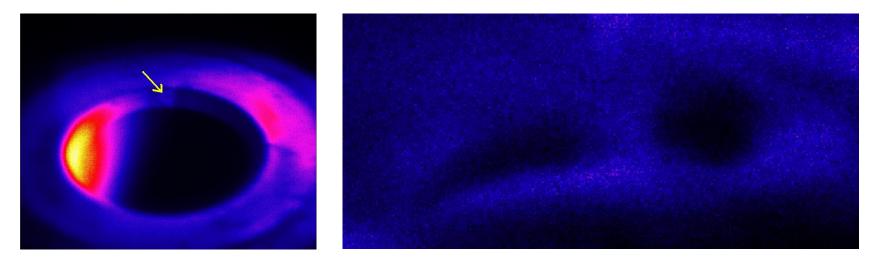




Static SIMS – Contamination on Diesel Injector

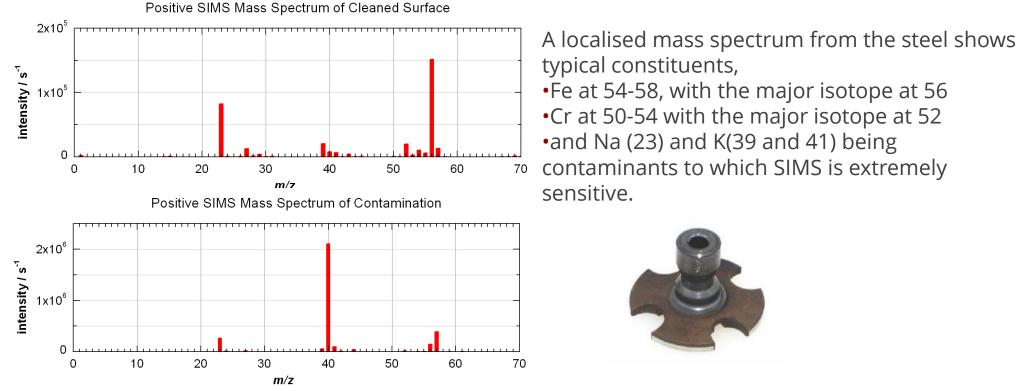
⁵⁶Fe SIMS images of the defective region. The right hand image shows detail in the position of the arrow, where something is blocking the iron signal from the steel. The very bright region is caused by ions being directed into the spectrometer by the angled face.







Static SIMS – Contamination on Diesel Injector

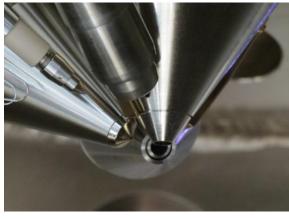


The localised mass spectrum from the defect is dominated by Ca.

The defect is Ca based and it is suggested that this is due to a bio-diesel catalytic production step. This known possible fuel contaminant is limited by EU regulations to 5mg/kg (summed with the Mg content).



Focused Ion Beam - SIMS







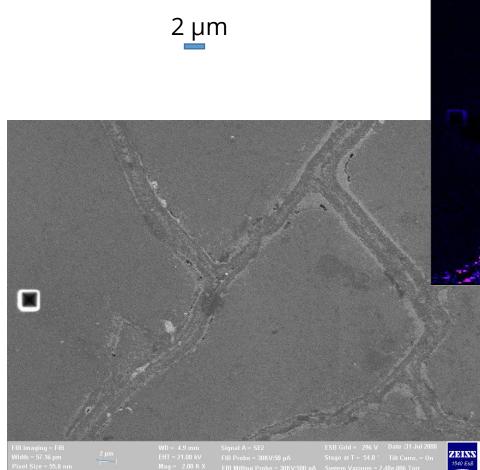
High sensitivity EQS

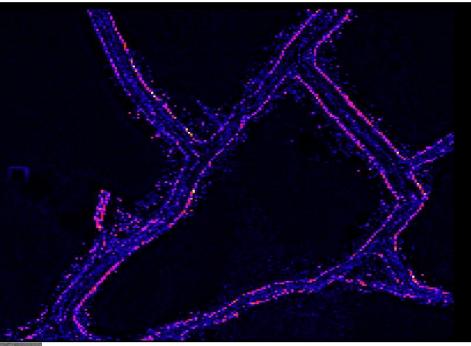
- Shielded low voltage extraction
- 50mm Z-Drive
- Depth profiling
- 3D and 2D Imaging
- Option for differential pumping
- Customisable length and fitting adaptors

Zeiss Nvision X-beam FIB with EQS



Focused Ion Beam - SIMS





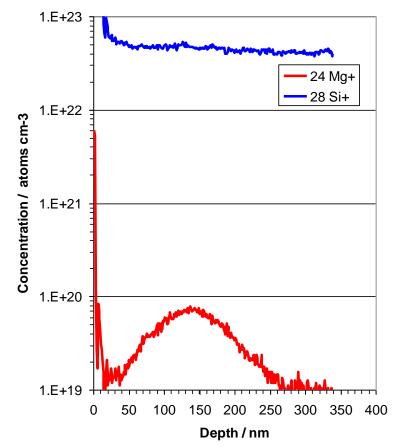
²⁷Al image showing concentration at grain boundary of LaSrCuFe oxide.

Sample: Richard Chater, Imperial College Instrument: Zeiss Neon Hiden EQS



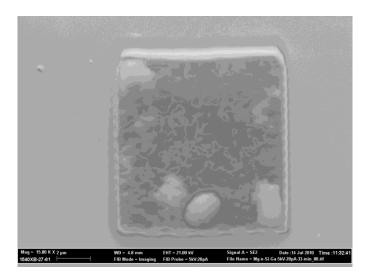
Focused Ion Beam – SIMS Depth Profiling

Positive Ion FIB-SIMS Depth Profile 1E15 Mg implant in Si 20pA 5keV Ga+



Peak of Mg implant is 7x10¹⁹ atoms cm⁻³

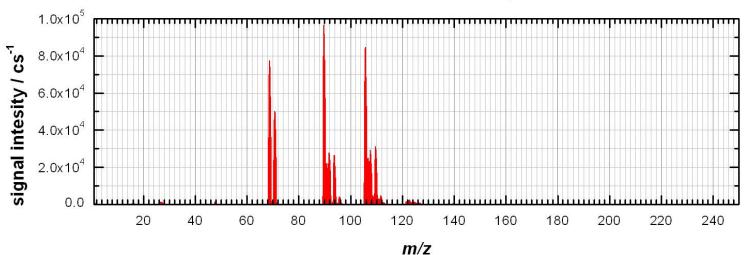
~ 0.15% atomic





Focused Ion Beam – SIMS Mass Spectrum

Analysis of individual zircon grains in a possible meteroritic rock sample - can FIB SIMS determine if it is actually likely to be extra terrestrial in origin?

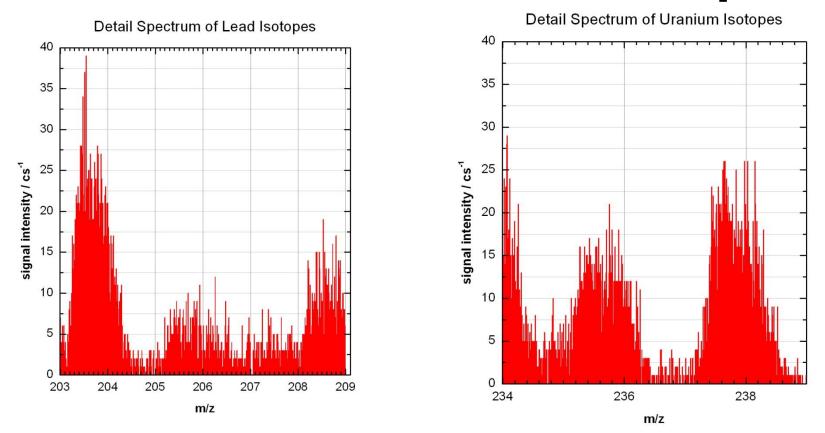


Zircon Positive SIMS Mass Spectrum

The spectrum above (plotted on a linear intensity scale) shows three significant groups. Ga from the ion probe is visible at m/z= 69 and 71 with Zr and ZrO isotopes appearing from 90 and 106 respectively. A small signal caused by ZrO2 is also discernable from 122.



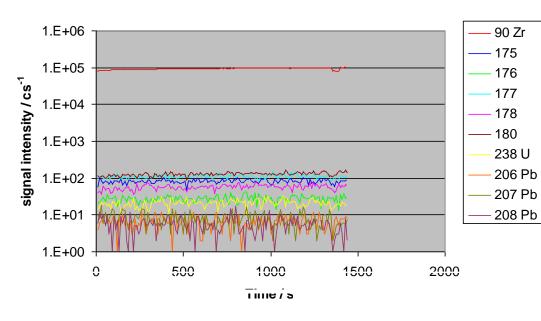
Focused Ion Beam – SIMS Mass Spectrum



SIMS can be used to analyse the isotopic abundance of elements, in this case low levels of Pb and U in the Zircon sample



Focused Ion Beam – SIMS Mass Spectrum



Meteorite zircon isotope measurement

Integrating specific isotopes over time allows greater statistical significance.

206 Pb = 945 counts (±3.3%) 207 Pb = 1141 counts (±3%)

Ratio 206/207 = 0.83± 0.05

Primordial ratio – 0.9 Present day crust ratio – 1.2

The sampled zircon is thus representative of the oldest material and therefore a good candidate for meteoritic origin.



New Hiden SIMS Software Suite

Philosophy

- Collect all data as images in order to optimise the efficient use of sample material and time by allowing gating and inspection after collection.
- Aim to make it simple, reliable and safe for the inexperienced operator to obtain depth profiles whilst retaining the flexibility that enables expert user develop new protocols and have full control over every aspect of the instrument.

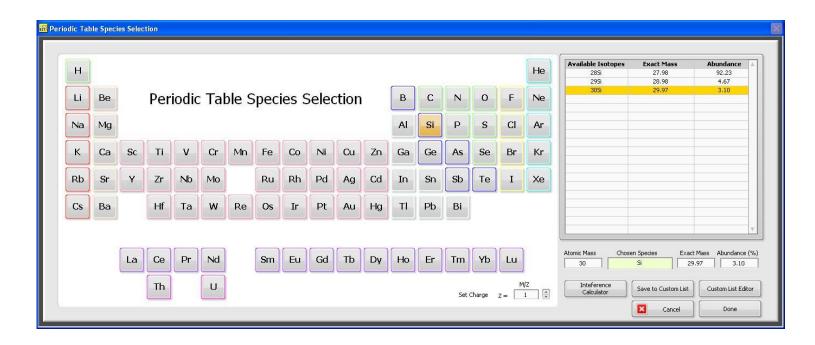


den Elemental SIMS M	ap				
HIDEN		Analysis Cor	ntrol		Version 0.7.3 Beta
ANALYTICA	Species	Frames	Resolution	Selected	
Disconnect		0	100×100		Settings
Setup Scan	-	0	100×100		Edit Library
Load Scan Setup	-	0	100×100		
Import Scan Setup	1	0	100×100		Caesium Gun
Run	L	0	100×100		Gas Gun
Analyse Data		No file loaded.			Exit

Control of the overall experiment and connection to the mass spectrometer

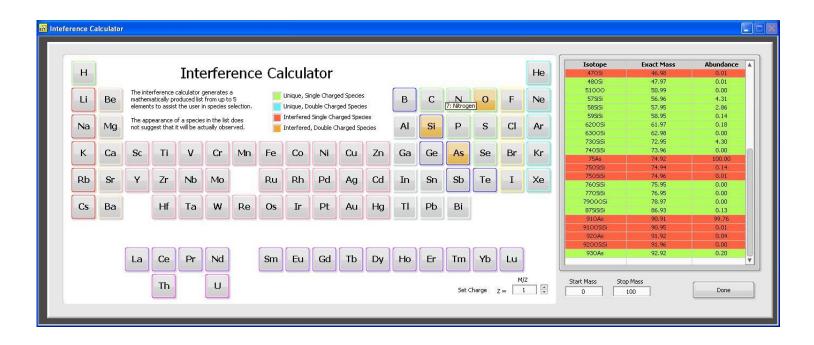






Mass for analysis is chosen from a periodic table and can include molecules and multiply charged species. Experienced users can also input data directly.





An integral interference calculator identifies possible mass interferences and suggests relative signal intensities





nvironment Scan Detecto	r) Sca	n Editor
Map resolution	100 × 100 🗸 points	
Scan parameter	X-Raster	💌 as X
Scan parameter	Y-Raster	💽 as Y
Acquisition cycles	Cycles 300	
Available species		
Count rate	less than 💌 20000	cps for 1 cycles
Maximum cycles	10 00:00:00	Estimated duration
Duration	00:10:00	
Requires Saving		Save Cancel

Global Scan Editor

The image resolution is chosen and any stopping criteria set.

The depth profile can be set to terminate automatically when the set criteria is reached - such as an interface, time or signal level.



Environmen	it Scan		Scan Edit	or
	Mode			
	+ ions SIMS		now More Sho	w All
		+ ions SIMS mode pa	rameters	
and the loss	Parameter	Value	Description	A
rs and value	es for the selected mode	2.80	٧	
	focus1	-34	V	
	focus2	-360	V	
	upper-plate	-52.80	¥	
	lower-plate	-72.90	V	
	extractor	-46	٧	
	energy	0.00	V	
	delta-m	0	%	
	resolution	0	%	
				v
				in the second se

Parameters can be set for each mass, typically a target bias offset is used to differentiate molecular and atomic species.

The parameters list has three levels of access and complexity.

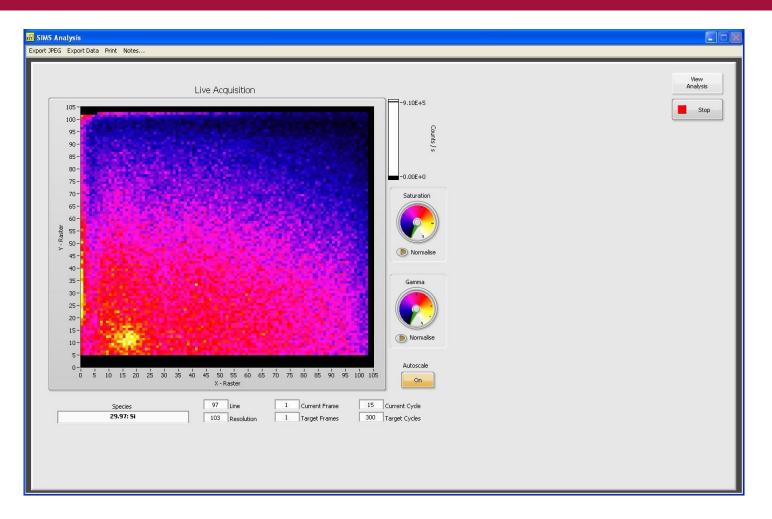


	Sca	an Setu	р	
	Analysis	setup requires sa	ving.	
Selected Species	Periodic	Selected		Edit Global Scan Settings
Custom Species 0.00: No Selection	Manual Species	Settings		Custom Species Library
Selected Species 69.92: Ge	Periodic Table	Selected	Ī	
Custom Species 0.00: No Selection	Manual Species	Settings		Save As New Template
Selected Species 11.01: B	Periodic Table	Selected		Open Template
Custom Species 0.00: No Selection	Manual Species	Settings		Save & Exit
Selected Species	Periodic Table	Select		Cancel Changes
Custom Species	Manual Species	Settings		Requires Saving
Selected Species	Periodic Table	Select		Total Species
Custom Species	Manual Species	Settings	*	Add Total Test Spec

The experiment flow shown here has three channels (Si, Ge and B).

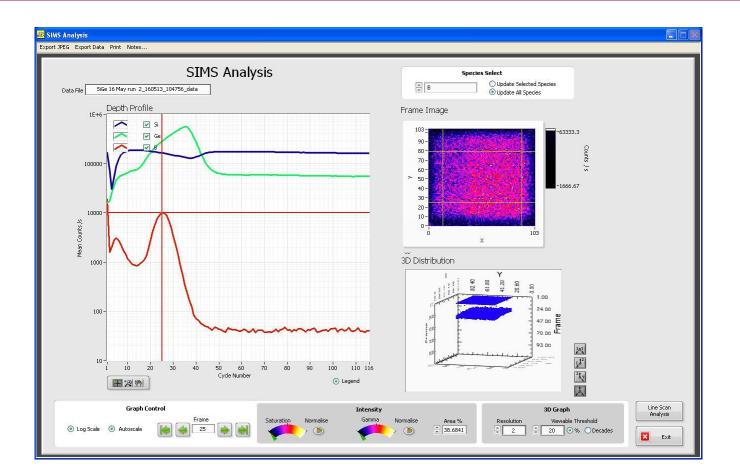
Species can be selected or deselected for analysis – this allows a non-expert user to control a range of experiments from a single template.





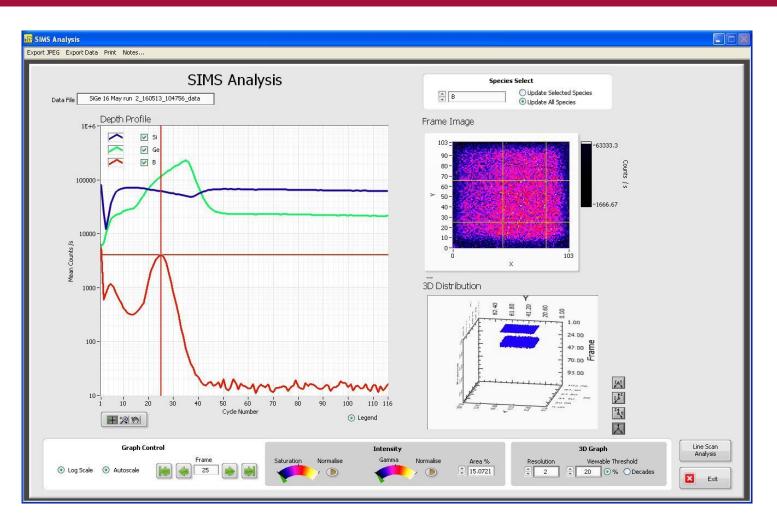
During analysis the live acquisition window displays the signal so that the progress of the experiment can be monitored and surface features observed.





During analysis the analysis window displays the depth profile, image data and a 3D representation of the distribution. It also controls the electronic gating.

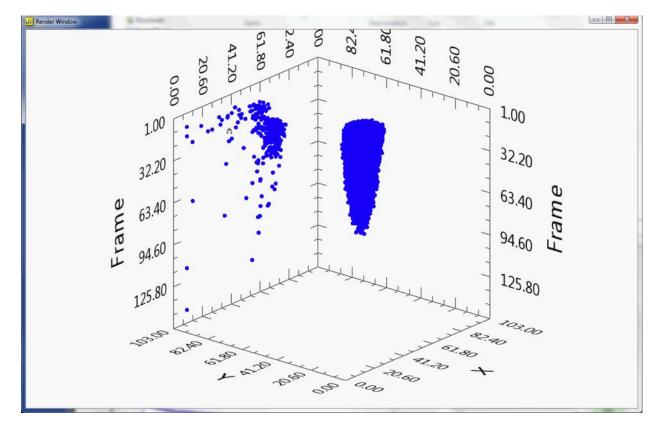




The electronic gate can be optimised independently and interactively for each mass and does not have to be concentric or square.



3D Profiling by SIMS



The video shows the mass resolved aluminium signal arising from aluminium oxide grit particles embedded in the work-piece after a grinding operation. Volume is $800\mu m$ square x 35 μm deep.



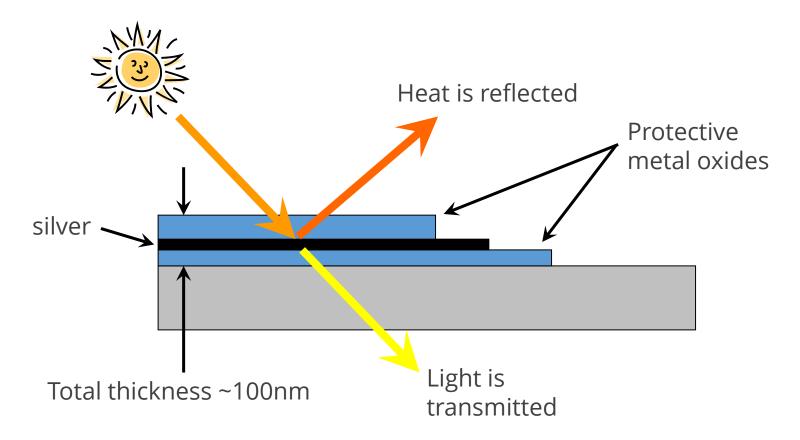
Low emissivity glass is installed in buildings to increase energy efficiency. In cold weather it reflects heat back into the building – reducing heating costs; in hot weather it reflects heat from the external environment reducing heat build-up within and lessening required air conditioning capacity.

This is achieved, primarily, through the inclusion of a sputter deposited (typically 10nm thick) metallic silver layer within a sandwich of protective oxides.

Surrounding layers may be chosen to impart a particular colour to the glass but ideally white light should pass through so that colours are rendered correctly within the building.



Low Emissivity Architectural Glass





SIMS can provide analysis of glass layers for:

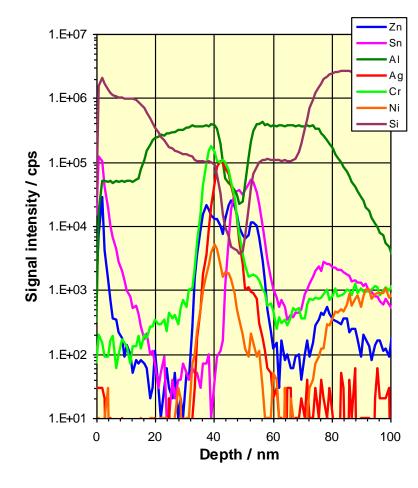
- Failure analysis, identification of defects, impurities and contamination
- Characterisation of processes
- Reverse engineering



Zinc Tin Oxide
Silicon Nitride
Aluminium Nitride
Zinc Aluminium Oxide
Nickel Chrome Oxide (NiCrOx)
Silver (10 nm)
Zinc Oxide
Zinc Tin Oxide
Aluminium Nitride
Glass Substrate

The diagram shows a typical low-e stack where the active silver layer is protected by a mixture of metal oxide layers.







The SIMS depth profile was collected using 5keV Ar ions focused to an 80µm spot and rastered over an area of 400 x 550µm. Positive secondary ions were collected and a 500eV electron flood was employed to prevent surface charging.



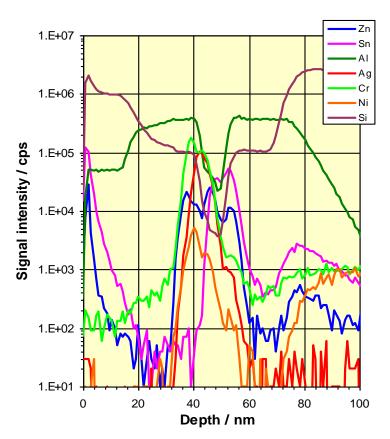
Beginning at the exposed surface, the first layer is extremely thin and is partly consumed by the pre-equilibrium region at the start of the analysis. However, zinc and tin signals are clearly present at the very surface. There is a high silicon signal (rising to a level almost of that in the glass substrate) suggesting that a thin SiO2 layer may exist in the vicinity of the ZnSnOx.

The silicon nitride layer is characterised by a uniform concentration of silicon, however, this layer also contains aluminium, estimated to be ~7% (atomic).

Beneath the SiN layer lies a similar thickness if AlN. Interestingly, throughout this layer the Cr signal is rising, albeit from three orders of magnitude below the eventual peak. SIMS is perfectly suited to the investigation of this type of low concentration feature and for the analysis presented here it was necessary to significantly reduce the sensitivity to ensure that the peak of the Cr signal did not saturate the detector.

The region below the AlN contains the thin silver layer and its associated thin protective barrier layers containing Zn, Al, O Ni and Cr. The design thickness of the NiCrOx layer is only 1 nm and there has been some mixing of this into the silver layer during analysis.

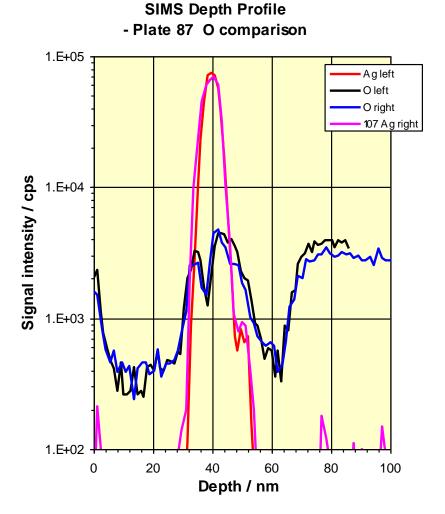
Immediately below the silver, the thin Zn and ZnSnO layers are visible, before the final AlN layer and the glass substrate.





Such a profile is very complex to quantify, however, by comparing similar profiles from different parts of the glass pane it is possible to investigate abnormalities.

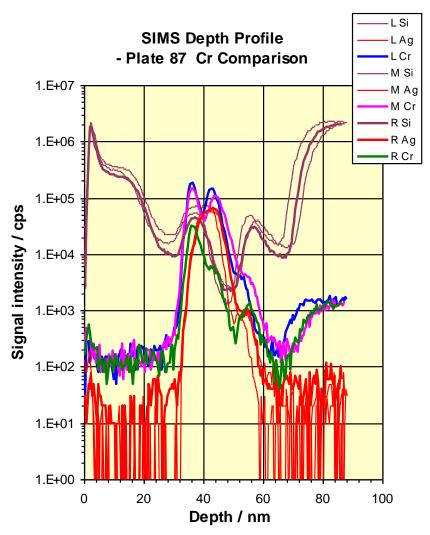
Here the silver and oxygen signals from left and right hand sides are overlaid, showing no difference.





When the Cr signals from the left (L), middle (M) and right (R) hand sides are overlaid it becomes immediately apparent that the right hand edge is deficient in Cr.

It should be noted that the NiCr layer is expected to be only about 1 nm thick and so this represents a very sensitive analysis.



- www.HidenAnalytical.com
- The Hiden website is an excellent resource with product pages, brochures, catalogues, product pages with some application notes, presentation and other information.
- Contact +44 1925 445225 for direct support.

